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- 5. (amended) A recombination device (1') according to claim 1, characterized in that the retarding layer (8) in the first sub region (T1) in particular is a porous layer composed of a bulk material, in which the catalyst body (6) is arranged.
- 6. (amended) A recombination device (1) according to claim 1, characterized in that the retarding layer (8) in the first sub region (T1) is deposited as porous cover layer onto the catalyst body (6).
- 7. (amended) A recombination device (1) according to claim 1, characterized in that several identical catalyst systems (2) are arranged parallel to each other.
- 9. (amended) A recombination device (1, 1') according to claim 1, characterized in that an up-current protection (10) is provided at the front end of the catalyst system (2), in inflow direction of the gaseous mixture.
- 10.(amended) A recombination device (1, 1') according to claim 1, characterized in that a down current protection (12) is arranged in outflow direction of the gaseous mixture, at the end of the catalyst system (2).